REMARKS

Claims 1-8 remain in this application and are currently amended. No new matter has

been introduced.

Objection to Oath/Declaration

Applicants inadvertently did not submit a newly executed oath on January 25, 2007, in

the Supplemental Response to the Office Action mailed August 10, 2006. Applicants are

currently having a new Oath/Declaration executed, and they will send it in as soon as it is

finished.

Rejection under 35 U.S.C. § 102(b)

Claims 1, 3, and 5-8 stand rejected under 35 U.S.C. § 102(b) as allegedly being

anticipated by Chow (U.S. Pat. No. 5,240,749). Applicants respectfully disagree.

As a preliminary matter, claim 1 has been amended to clarify that the pulsed discharge is

a repeated succession of a low-power state and a high-power state; i.e., the pulsed discharge

cannot be only a succession of one low-power state and one high-power state. This amendment

is supported by the specification as filled; particularly by paragraphs [0046]-[0048], [0054], and

[0059]. Applicants also note that the power generated by the microwave generator is periodic with

time; however, the signal is not necessarily strictly periodic.

First, the Patent Office asserts that the American Heritage Dictionary (4th Edition, Houghton

Mifflin Company, 2000) defines a pulse as "a brief sudden change in a normally constant quantity".

The Office, however, disregards the full meaning of "pulse", which is clearly defined as a brief and

5

<u>sudden</u> change or a <u>series of intermittent occurrences</u>:

3. Physics

McDonnell Boehnen Hulbert & Berghoff LLP 300 South Wacker Drive

300 South Wacker Driv Chicago, IL 60606 Tel. 312-913-0001 Response to Final Office Action Mailed January 3, 2007 Application No. 10/541,970 Attorney Docket No. 05-583 April 3, 2007 a. A brief sudden change in a normally constant quantity: a pulse of current; a pulse

of radiation.

b. Any of a series of intermittent occurrences characterized by a <u>brief sudden</u>

change in a quantity. (Emphasis added)

Dictionary.com (Dictionary.com Unabridged (v 1.1); Random House, Inc.; Further.

http://dictionary.reference.com/browse/pulse, accessed on April 3, 2007) defines a pulse as:

6. Physics. a single, abrupt emission of particles or radiation.

12. Physics. to emit particles or radiation periodically in short bursts. (Emphasis added)

Furthermore, The Compact Oxford English Dictionary (2nd Edition, Oxford University Press, 1987)

defines a pulse as:

4.a. The rhythmical recurrence of strokes, vibrations, or undulations; beating, vibration.

4.b. each of a rhythmical successions of strokes or undulations.

2.a. To beat, throb, as the heart, etc.

3.a. To perform or exhibit a rhythmic movement; to beat, vibrate, undulate.

As amended, claim 1 discloses that the gas is subjected to periodic pulsed discharges. In

light of the above definitions, the concept of "periodic pulsed discharges" should be considered to

be: 1) a brief and abrupt change of power density applied to the gas, and 2) the series of

occurrences of said pulses are repetitive and periodic. On the other hand, the application of two

successive power states for a long period of time, such as several seconds or more, is not

considered a pulse discharge. These power states should be considered plateaus.

Chow does not disclose a pulsed discharge of power, as currently claimed. Chow clearly

applies two successive, constant power densities: the first occurs in the 1st step and has

duration of one hour; and the second, which has the higher power level than the first, occurs in

6

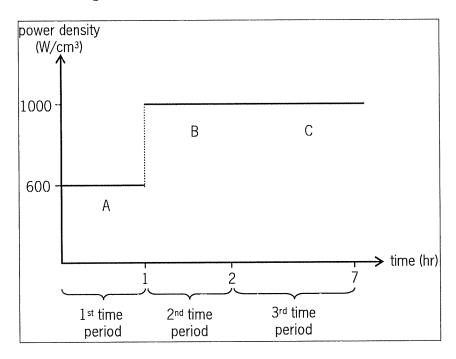
McDonnell Boehnen Hulbert & Berghoff LLP 300 South Wacker Drive

Chicago, IL 60606 Tel. 312-913-0001

Response to Final Office Action Mailed January 3, 2007 Application No. 10/541,970 Attorney Docket No. 05-583

April 3, 2007

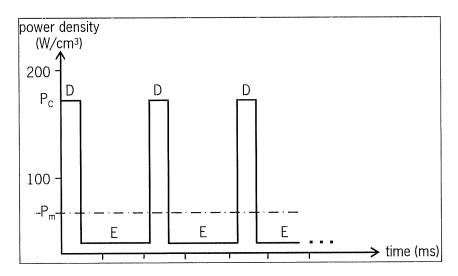
the 2nd and 3rd step (duration of one hour in the 2nd, and duration of five to six hours in the 3rd step). Please see Chow Figure bellow:



Chow Figure: technical effect \underline{A} forms diamond-like ball; technical effect \underline{B} forms diamond faces on top of the diamond-like ball; and technical effect \underline{C} causes the faces on top of the particles to be joined together into a semi-continuous diamond.

Chow discloses that the transition between the two power densities is done by only <u>one</u> "increase" (claim 1, lines 17-23). Chow does not disclose that this "increase" is *brief*, *sudden*, or *abrupt*, nor that is *periodical in short burst*. Chow does not disclose or suggest that these two power densities are repeated. That is, they cannot be considered to be periodic, since they don't recur at intervals of time. Thus, according to the above definitions, Chow's "increase", which is neither brief nor abrupt, cannot qualify as a "pulsed discharge," as required by the claims.

In contrast to Chow, the current invention comprises the additional feature of applying <u>periodic</u> <u>pulsed</u> discharges, forming a <u>repeated</u> succession of a low-power state and a high-power state. Please see Invention Figure bellow:



Invention Figure: technical effect of \underline{D} increases the characteristics of the plasma (high concentration of atoms H and C-containing radicals), thus high deposition rate; and technical effect of \underline{E} decreases the mean power of discharge, thus the wall temperature remain low and less H-atoms recombine.

Applicants note that Chow's method has the same deficiencies as the prior art described on page 1, lines 8-17 of this application, and as such does not anticipate the currently pending claims, which are directed towards curing these deficiencies.

In view of the foregoing, the Chow reference does not disclose the currently claimed invention. Thus, the applicants respectfully request reconsideration and withdrawal of the § 102(b) rejections of claims 1, 3, and 5-8.

Rejection under 35 U.S.C. § 103(a)

Claims 2, 4, and 7-8 stand rejected under 35 U.S.C. § 103(a) as allegedly being

unpatentable over Chow (U.S. Pat. No. 5,240,749) in view of Kawarada et al. Applicants

respectfully traverse this rejection.

As discussed above, Chow discloses a method wherein the power densities are applied

increasingly in a stair-like manner on hour time scale. Chow does not disclose or suggest the use

of the periodic pulsed discharges in the manufacturing of a diamond film. The use of the <u>periodic</u>

pulsed discharge aims at improving the growth rate of the diamond films manufacturing. Indeed,

due to the repeated succession of the low-power states and high-power states, the walls of the

chambers do not heat up. This prevents H-atoms from recombining, thus their concentration

remains higher in the plasma. Consequently, as H-atoms constitute activators of the reaction, the

diamond film may be deposited at a higher rate for a constant power consumed.

Nothing in Chow suggests the existence of the technical problem caused by warming of the

apparatus walls. Chow does not indicate how to solve this problem; in fact, Chow does not even

mention it. One must conclude that either Chow does not solve this problem or Chow's method

involves a means to cool the walls (please see the specification: Background of the Invention).

Indeed, if Chow does not cool the walls of the chamber, the recombination of H-atoms increases.

Under these conditions, a diamond film that has good surface characteristics is obtained, but with a

low rate of manufacturing. The present invention, however, aims exactly at that: the improvement of

the low rates of manufacturing.

Kawarada et al., which discloses the range of the plasma temperature and density, does

not cure the deficiencies of the Chow reference. Combining Chow and Kawarada would afford a

9

McDonnell Boehnen Hulbert & Berghoff LLP 300 South Wacker Drive

300 South Wacker Driv Chicago, IL 60606 Response to Final Office Action Mailed January 3, 2007 Application No. 10/541,970 Attorney Docket No. 05-583

Tel. 312-913-0001

April 3, 2007

method that does not use the pulsed discharges of the current claims, so the combined

references do not make the currently claimed invention obvious.

Further, in order to obtain the method of the present invention, the person of ordinary skill in

the art, having the Chow and Kawarada et al. references at hand, would need to, at a minimum:

1. substantially decrease the duration of each plateau, from about 1h to a few ms;

2. repeat, for a time to determine, the application of a low-power state and a high-

power state, in order to obtain a periodic signal, forming a repeated succession of a low-

power state and a high-power state; and

3. determine, according to the conditions of the invention and the desired growth rate,

the respective power densities of the low-power state and the high-power state, as well as

the ratio of their duration.

All of these would have to be done even though there is no teaching, suggestion,

motivation, or reason for the person of ordinary skill in the art to do so. Further, to do so would

require the person of ordinary skill in the art to perform a great number of experiments, calculations

and simulations on the plasma modelling to modify the method disclosed by Chow in order to obtain

the claimed method. Without a reason to do so, Applicants fail to see how the person of ordinary

skill in the art would come up with the currently claimed invention. This implies that the differences

between the claimed method and Chow in light of Kawarada et al. are not obvious.

In view of the above arguments, Chow in view Kawarada et al. does not render the

currently claimed invention obvious. Therefore, the applicants respectfully request

reconsideration and withdrawal of the § 103(a) rejection of claims 2, 4, and 7-8.

McDonnell Boehnen Hulbert & Berghoff LLP 300 South Wacker Drive

300 South Wacker Drive Chicago, IL 60606 Response to Final Office Action Mailed January 3, 2007 Application No. 10/541,970 Attorney Docket No. 05-583 April 3, 2007

10

CONCLUSION

Applicants respectfully contend that all requirements of patentability have been met. Allowance of the claims and passage of the case to issue are therefore respectfully solicited.

The Examiner is urged to contact the Applicants' undersigned representative at (312) 913-2114 if the Examiner believes a discussion would expedite prosecution of this application.

Respectfully submitted,

Date: April 3, 2007

Bradley W. Crawford Registration No. 50,494

Telephone: 312-913-2114 Facsimile: 312-913-0002

McDonnell Boehnen Hulbert & Berghoff LLP 300 South Wacker Drive Chicago, IL 60606